

What is MBE? Why is It at a Nanotechnology Center?

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Sandia National Laboratories

To be presented at Taylor University

March 5, 2009

MBE is a technique that is about 40 years old and uses large pieces of equipment yet is a major part of the Center for Integrated Nanotechnologies (CINT). A brief explanation of what CINT is will be presented first, followed by what MBE is and what it can do. Examples of the range of nanotechnology that are being impacted by the MBE system at CINT will then be presented.



What is MBE?

Why is it at a Nanotechnology Center?

John Reno
Center for Integrated Nanotechnology
Sandia National Laboratories



This work was performed in part at the US Department of Energy, Center for Integrated Nanotechnologies, at Los Alamos National Laboratory (Contract DE-AC52-06NA25396) and Sandia National Laboratories (Contract DE-AC04-94AL85000).





Distributed Facilities to Meet National Needs



**Albuquerque,
New Mexico**



**Kauai Test Facility,
Hawaii**



**Tonopah Test Range,
Nevada**



**Yucca Mountain,
Nevada**



WIPP, New Mexico



Pantex, Texas

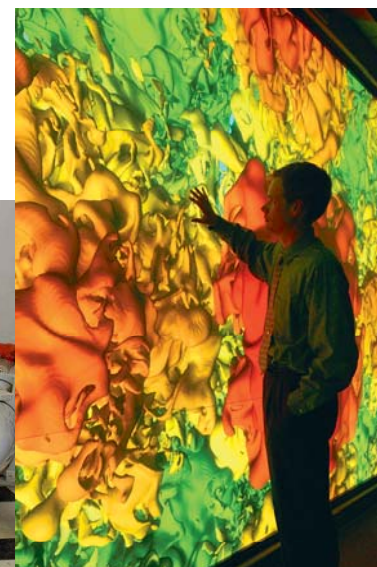
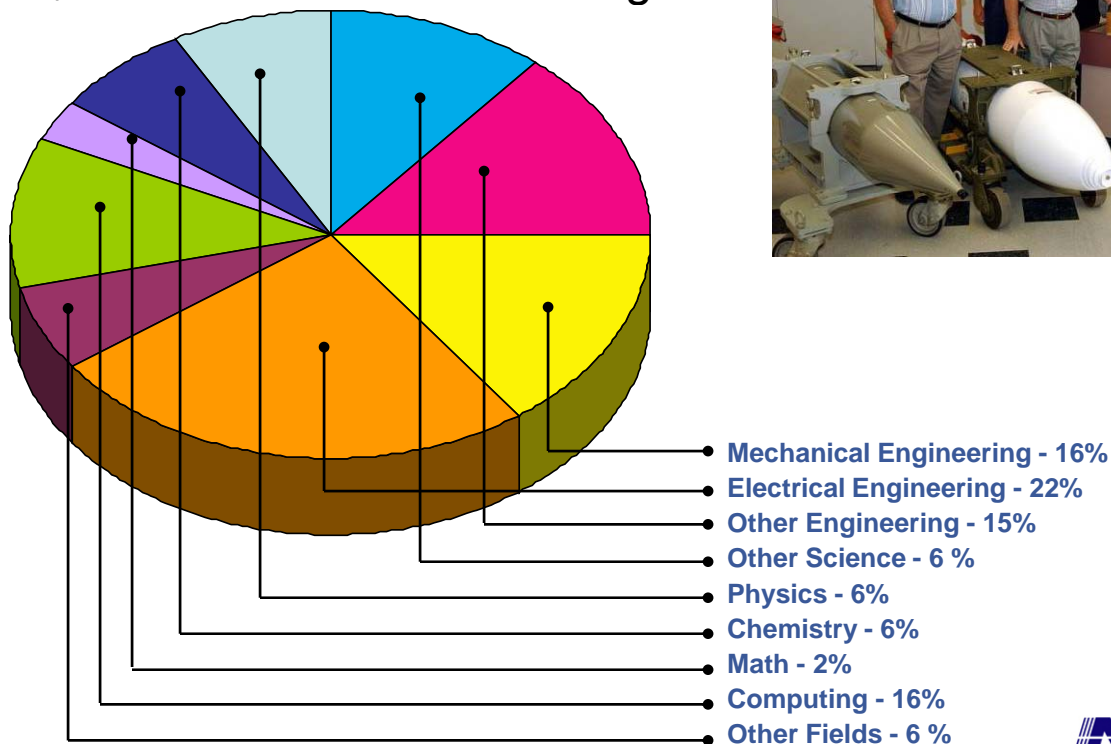


Livermore, California



Highly Skilled Workforce

- More than 8,600 full-time employees
- More than 1,500 PhDs and 2,700 MS/MAs
- 2,200 on-site contractors
- \$2.33 billion FY06 total budget





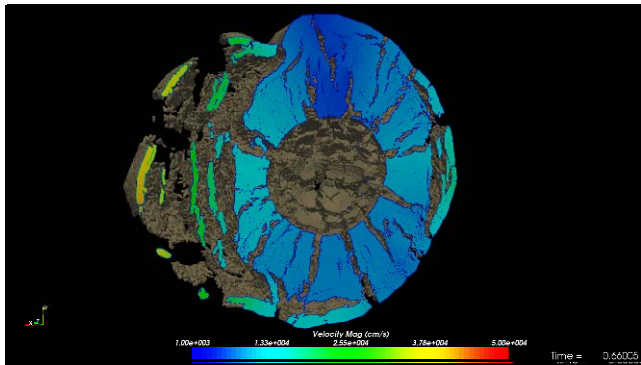
Our Business: National Security

- **Core Purpose:** to help our nation secure a peaceful and free world through technology.
- **Highest Goal:** to become the laboratory that the United States turns to first for technology solutions to the most challenging problems that threaten peace and freedom for our nation and the globe.

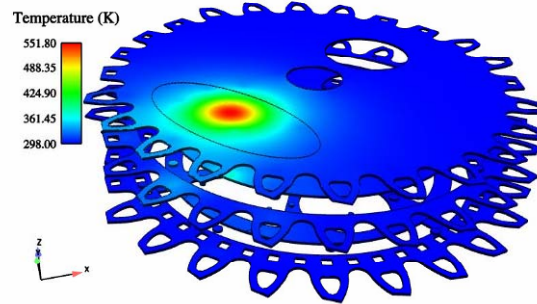




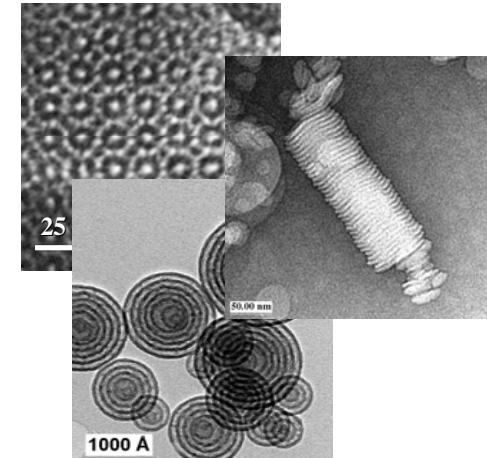
Our Mission Focus Relies on Strong Science and Engineering



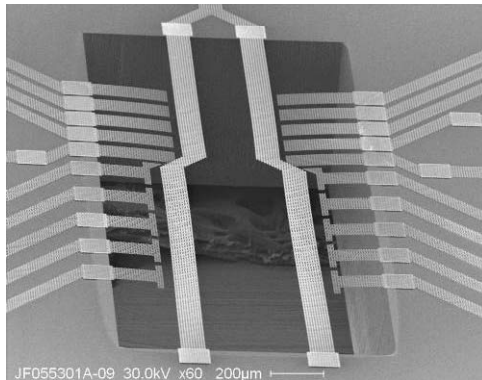
Computational and Information sciences



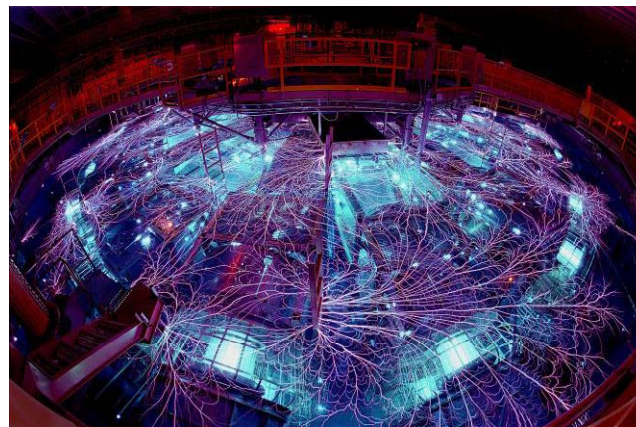
Engineering Sciences



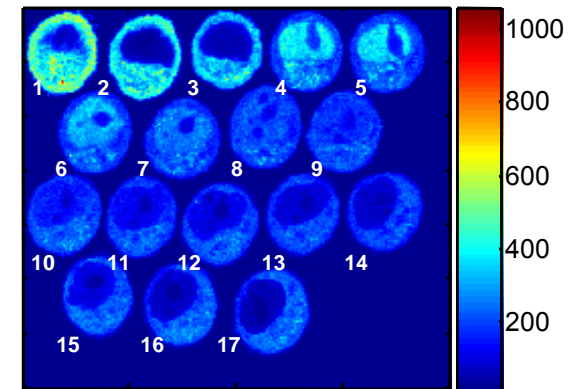
Materials Science and Technology



Microelectronics and Photonics



Pulsed Power



Bioscience



Sandia's Primary Mission: *Support the Nuclear Deterrent*

Ensure that the stockpile, the infrastructure, and the people are fully capable of supporting our nation's deterrence policy

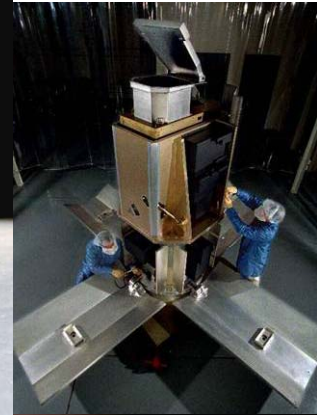


**Computer
modeling of B61
tail assembly**



Four Mission Areas

- Nuclear Weapons
- Defense Systems and Assessments
- Energy, Resources, and Nonproliferation
- Homeland Security and Defense





Provide Exceptional Systems Engineering and Programmatic Support for the Stockpile

- Research, Design, and Development of Non-Nuclear Components (96% of Total NW Parts)
- Life Extension of Nuclear Weapons
- Neutron Generator (NG) Manufacturing
- Stockpile Support – maintenance, military liaison, surveillance, dismantlement, logistics
- Nuclear Materials Protection



C4/D5
Missile



Defense Systems & Assessments Programs

- Proliferation Assessment
- Remote Sensing and Verification
- Surveillance, and Reconnaissance
- Integrated Military Systems



**Shuttle Heat Shield
Inspection**



**Future Combat
System Integrated
Support Team**



Energy, Resources, and Nonproliferation

Energy, Water, and Security Enabled by Science & Technology

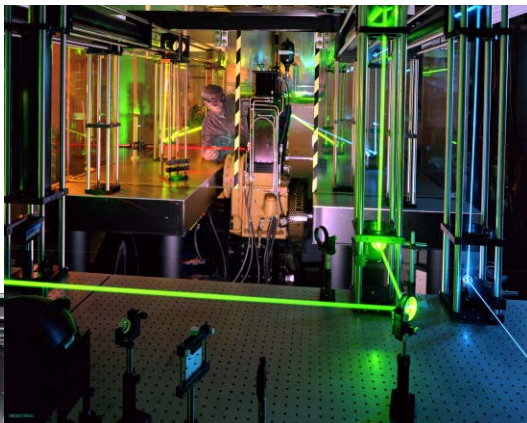
- Secure energy supplies for national security
- Clean, abundant and affordable energy
- Water research
- Infrastructure protection



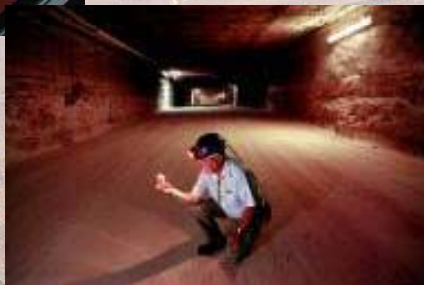
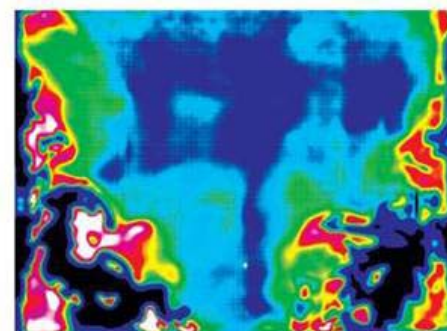


Energy, Resources, and Nonproliferation

Making the World a Safer Place



- Science, Technology, and Engineering Base
- Hydrogen Research
- Nuclear Power Research
- Waste Management

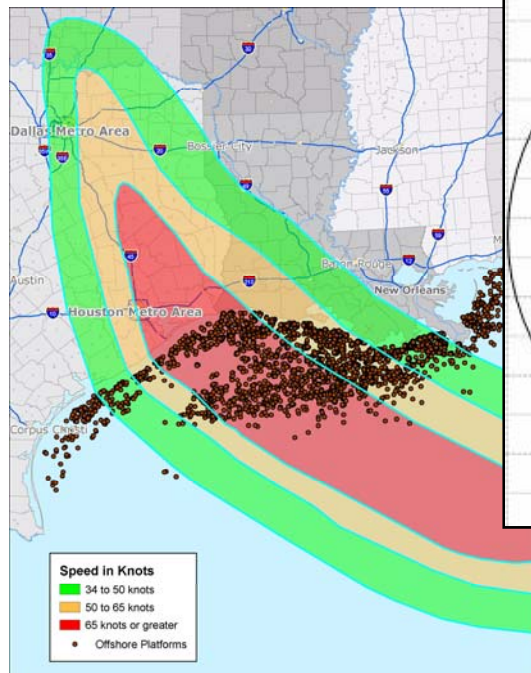




Homeland Security and Defense

Mitigating the risk of catastrophic events and enhancing the nation's ability to respond and recover

Risk Management and Infrastructure Protection



Homeland Defense and Force Protection



Catastrophic Event Mitigation



Catastrophic Event Mitigation



- Chemical and Biological Countermeasures
- Radiological and Nuclear Countermeasures
- Explosives Countermeasures
- Information Analysis
- Red Teaming
- Border and Transportation Security
- Systems Analysis





The DOE Center for Integrated Nanotechnologies (CINT)

DOE Center for Integrated Nanotechnologies
Sandia National Laboratories
Albuquerque, NM 87185-1315



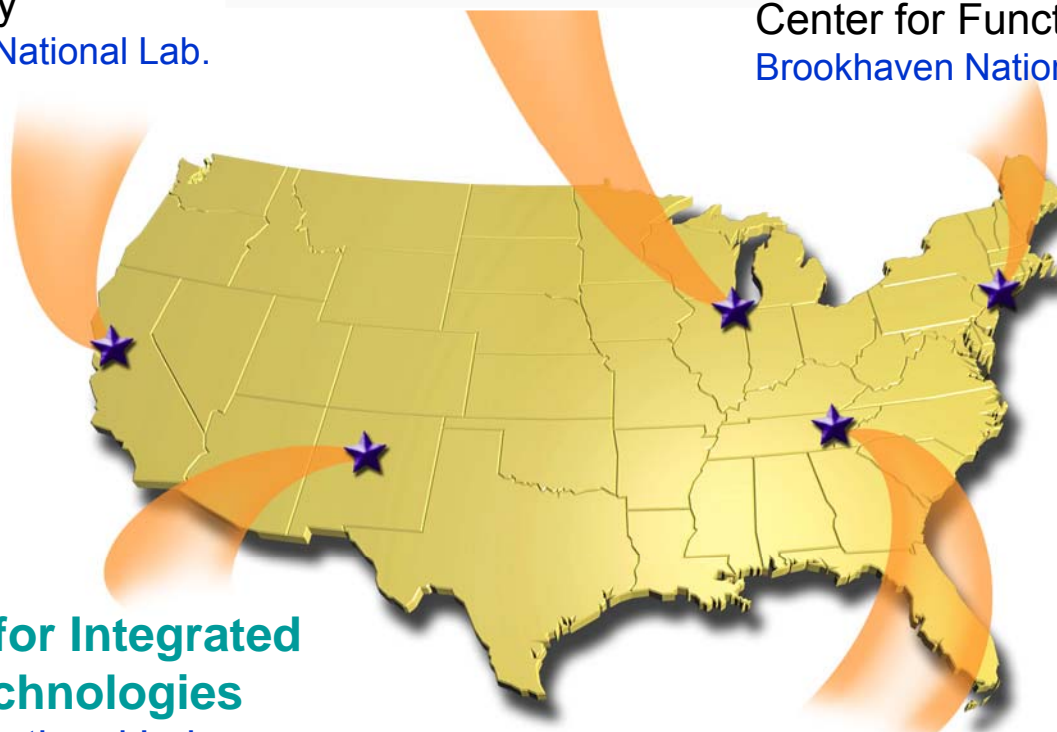


CINT is one of five U.S. Dept. of Energy Nanoscience Centers

Center for Nanoscale Materials
[Argonne National Lab.](#)

Molecular Foundry
[Lawrence Berkeley National Lab.](#)

Center for Functional Nanomaterials
[Brookhaven National Lab.](#)



**Center for Integrated
Nanotechnologies**
[Sandia National Labs.](#)
[Los Alamos National Lab.](#)

Center for Nanophase Materials Sciences
[Oak Ridge National Lab.](#)



CINT has capabilities for synthesis, characterization and integration

Characterization Wing

- TEM, SEM
- Low Temp Transport
- Scanning Probe Microscopy
- Ultra-fast Laser Spectroscopy

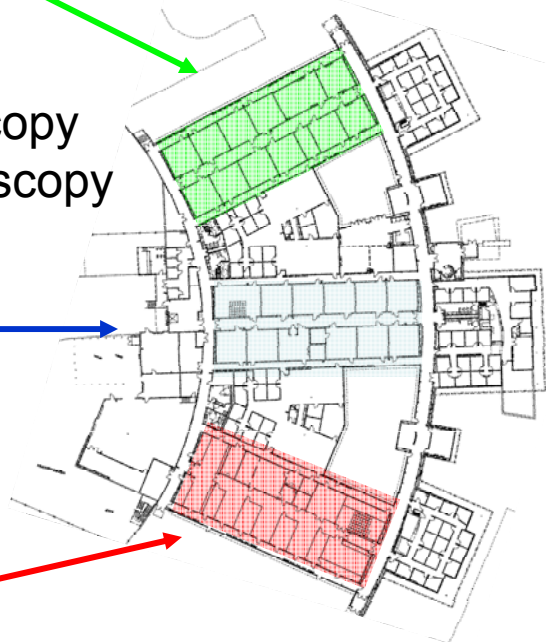
Synthesis Wing

- Molecular Beam Epitaxy
- Chem & Bio labs
- Molecular films

Integration Lab

- E-beam lithography
- Photolithography
- Deposition & Etch
- SEM/FIB

Core Facility



Gateway to Los Alamos

- NSOM, AFM
- Environmental SEM
- Nano-indenter
- Pulsed Laser Dep.
- Ultra-fast Spectroscopy
- Computer Cluster
- Visualization Lab





Science Thrusts

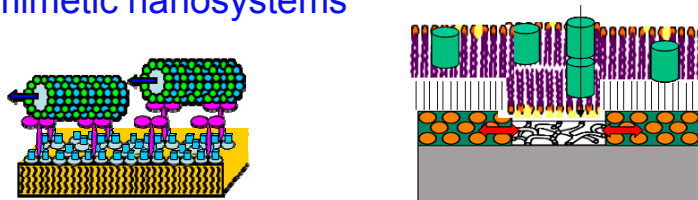
Nanophotonics & Optical Nanomaterials

Synthesis, excitation and energy transformations of optically active nanomaterials and collective or emergent electromagnetic phenomena (plasmonics, metamaterials, photonic lattices)



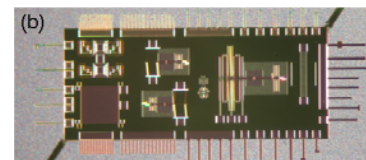
Soft, Biological, & Composite Nanomaterials

Solution-based materials synthesis and assembly of soft, composite and artificial bio-mimetic nanosystems



Nanoscale Electronics and Mechanics

Control of electronic transport and wavefunctions, and mechanical coupling and properties using nanomaterials and integrated nanosystems



Theory & Simulation of Nanoscale Phenomena

Assembly, interfacial interactions, and emergent properties of nanoscale systems, including their electronic, magnetic, and optical properties





CINT is a DOE/BES National User Facility

- No-fee access based on scientific quality
- Fee required for proprietary work
- Collaborative research or access equipment
- Short & long term projects (1 year, renewable)
- Rapid Access Proposals
- ***Spring Call for User Proposals is now open through March 16!***

<http://CINT.sandia.gov> or <http://CINT.lanl.gov>





CINT has attracted widespread interest

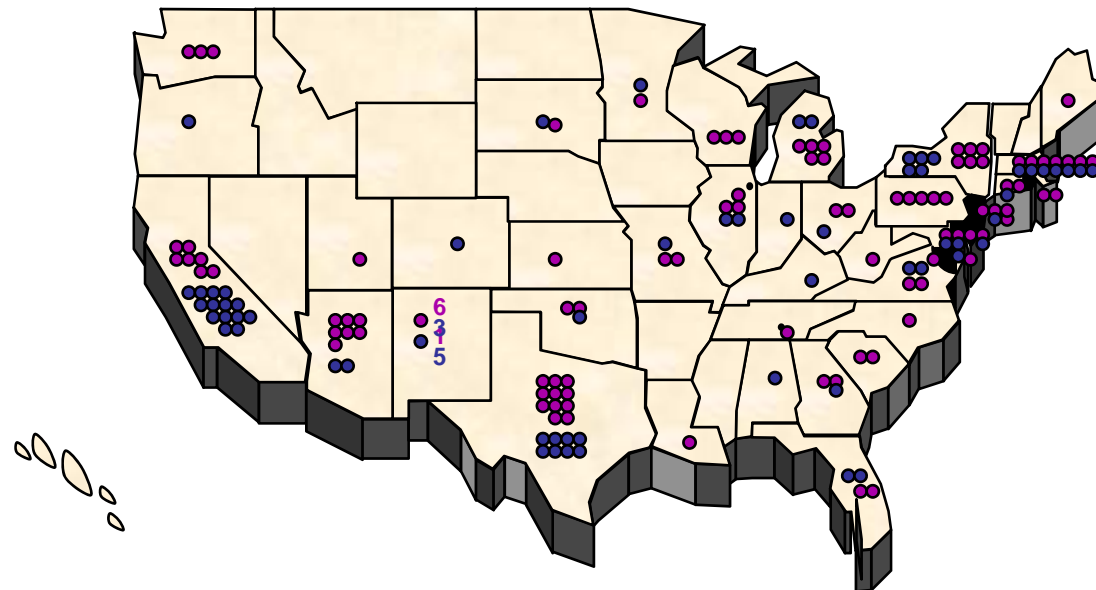
User Proposals

175 submitted; 130 accepted (74%) in 2006

101 submitted; 79 accepted (78%) in 2007 (+13 Rapid Access)

172 submitted; 160 accepted (93%) -- Spring 2008 (+13 Rapid Access)

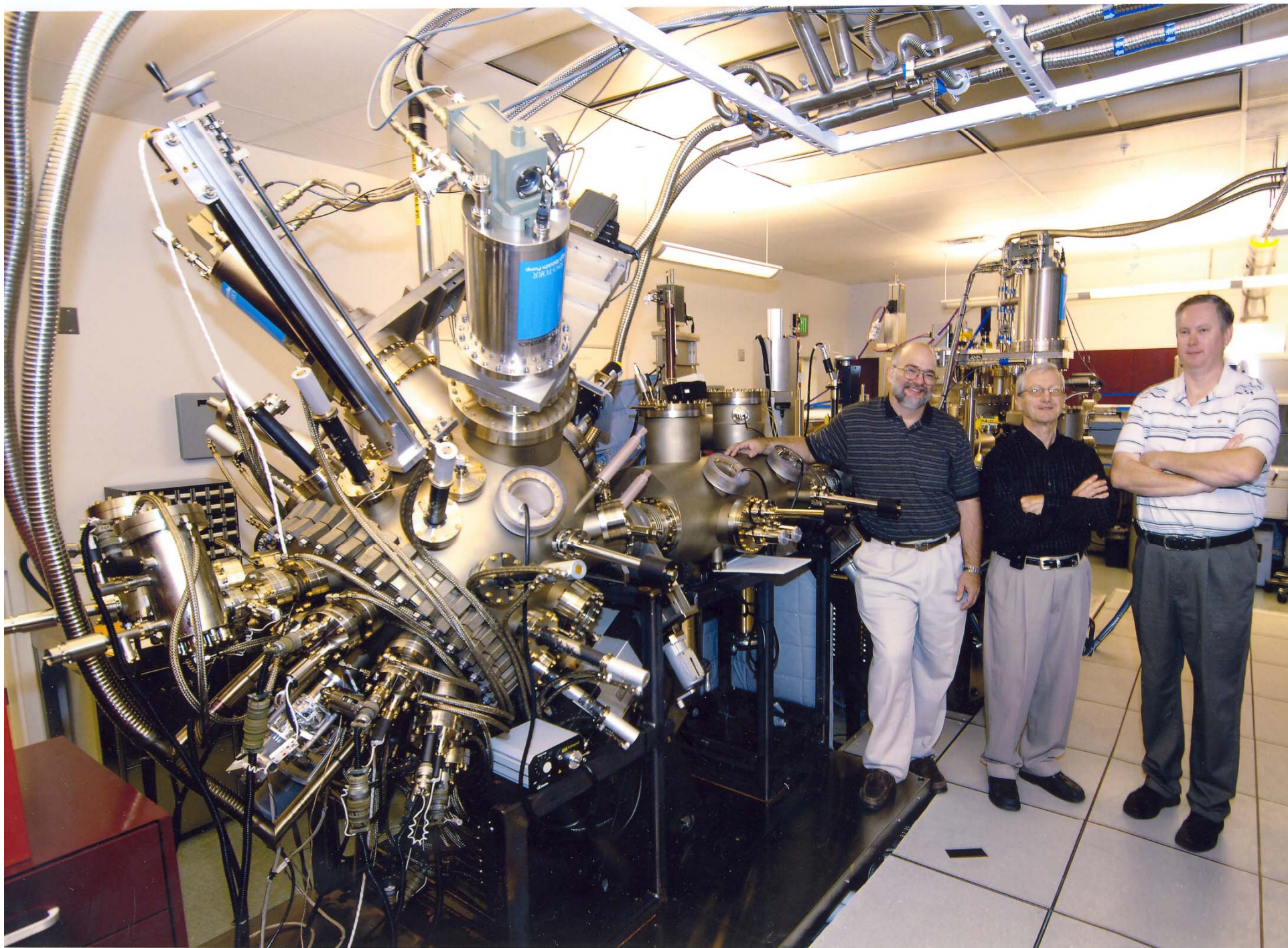
119 submitted; 107 accepted (90%) -- Fall 2008



*425 researchers involved in current projects,
representing 36 States and 14 Foreign Countries*



31.07.2007





What Is MBE?

- Clearly not “nano”
- Not a new technique (~1970)

~~Many Boring
Evenings~~

~~Mega Buck
Evaporator~~

Molecular Beam Epitaxy



Molecular Beam Epitaxy

Elemental

- Al
- Ga
- As₄

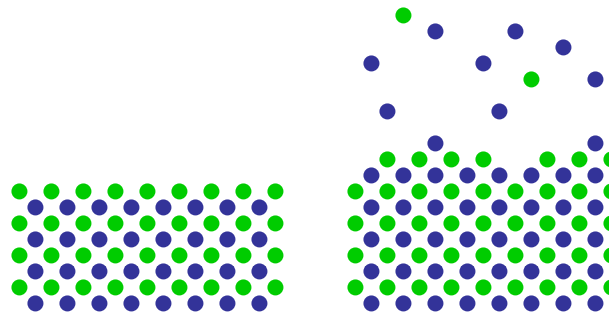
- Directional
- UHV => no scattering
- Mechanical Shutter
start and stop
- Change Materials

Same crystal
structure as
substrate

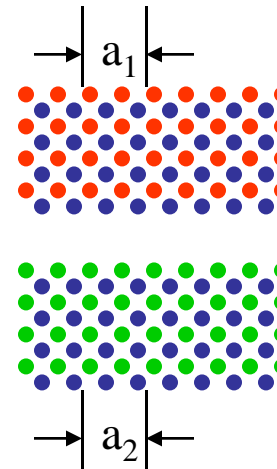
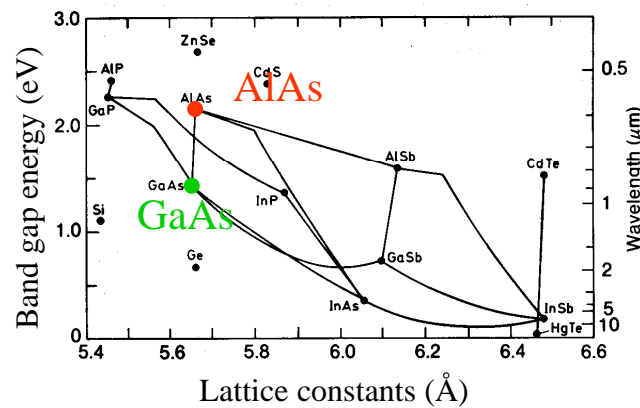


Ultra-low disorder GaAs/AlGaAs

1. Epitaxial growth



2. Lattice matching





Typical High Mobility Structure

Electrons
confined

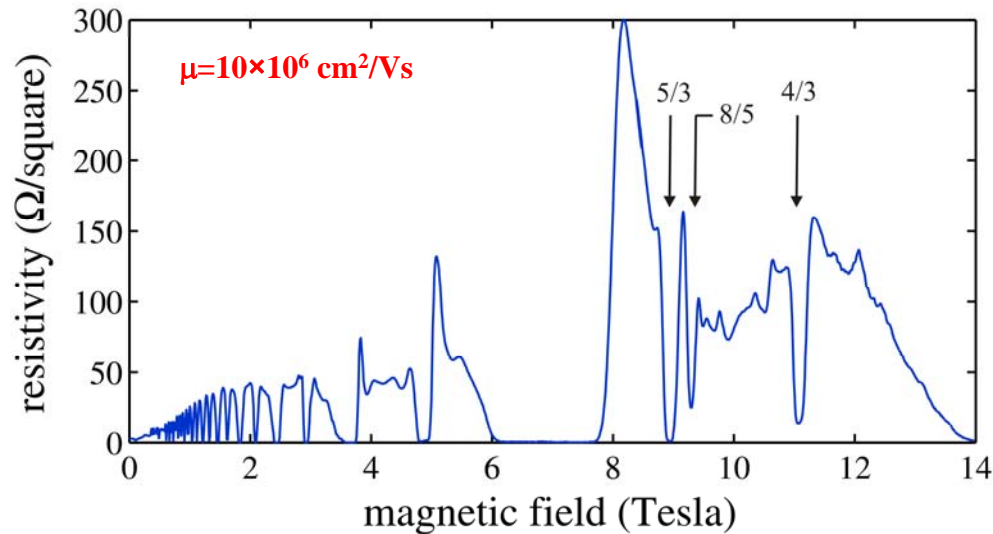


Cap
AlGaAs
GaAs QW
AlGaAs
Buffers
GaAs Substrate



Low Temperature Transport

High mobility 2D electrons



Quantum Hall Effect
Fractional Quantum Hall effect

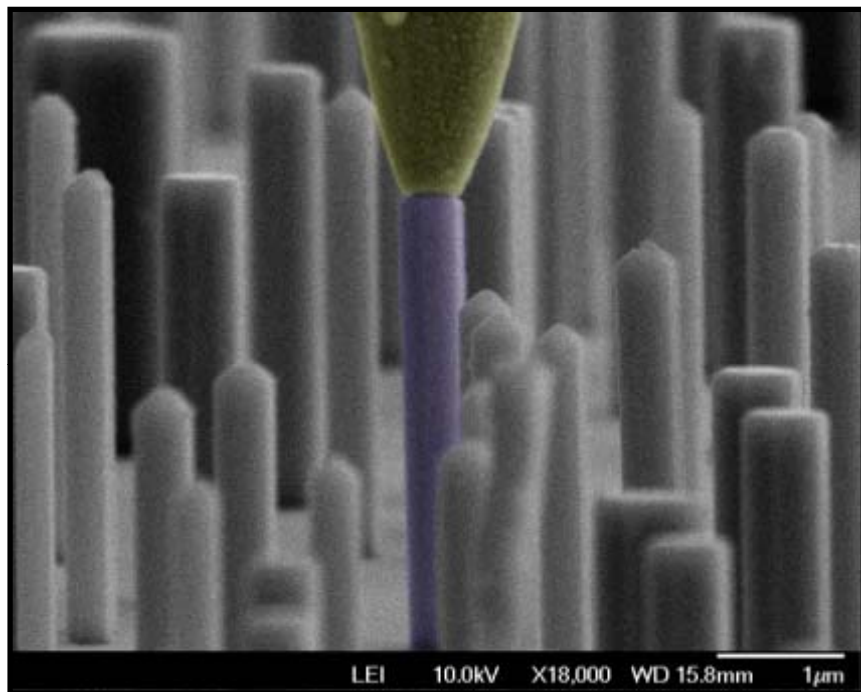
Length scales at low temperature

Quantum interference: 100 μm
Ballistic transport: 10 μm
Size quantization: $\sim 500 \text{ \AA}$

Nano scales but
not technically nanomaterials

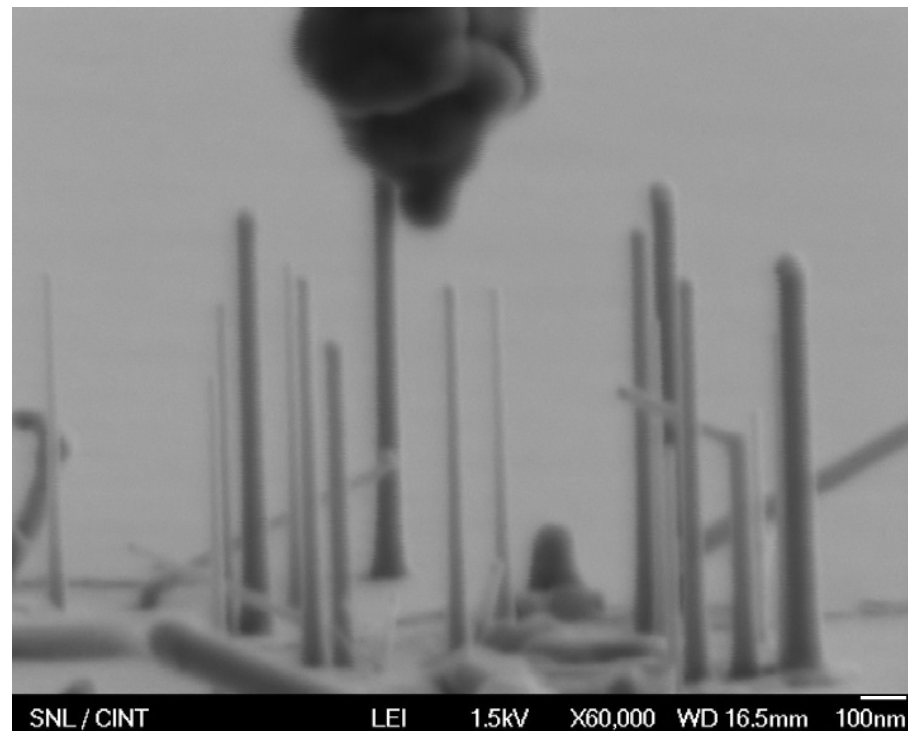


Nanowires



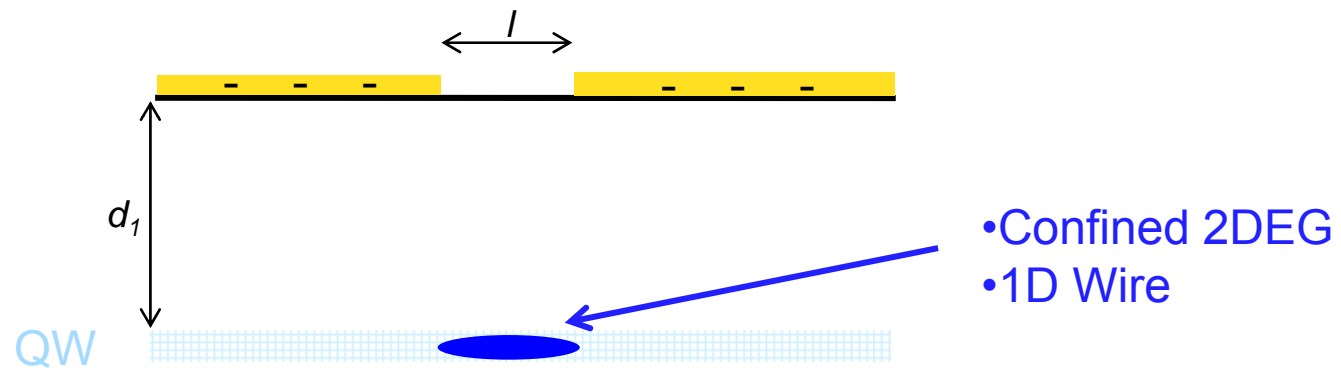
GaN rods $\sim 0.5\mu\text{m}$ diameter

Ge nanowires $< 100\text{nm}$ diameter





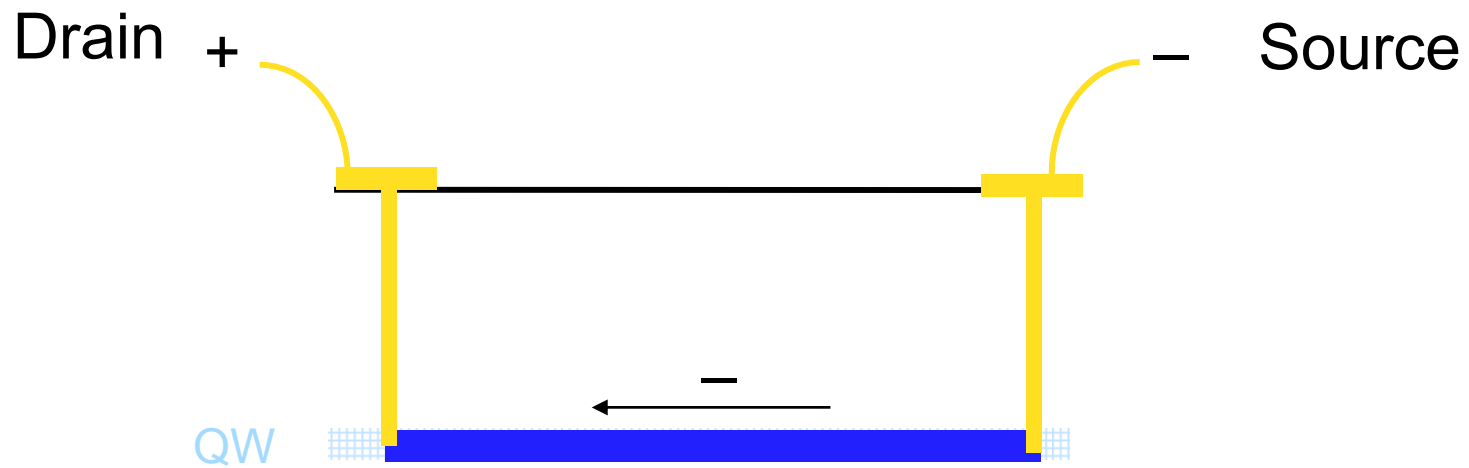
Gated Electronic Structures



- Gate dimension (l) of $\sim 100\text{nm}$ can be achieved



Quantum Wires



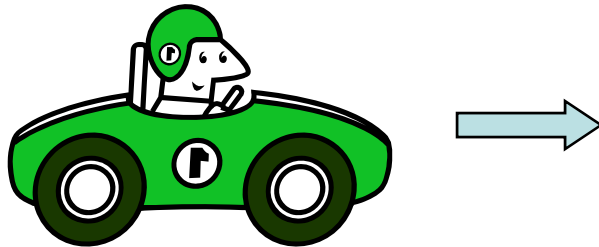


Ballistic conductance

Electrons *do not scatter* in a clean one-dimensional (1D) wire

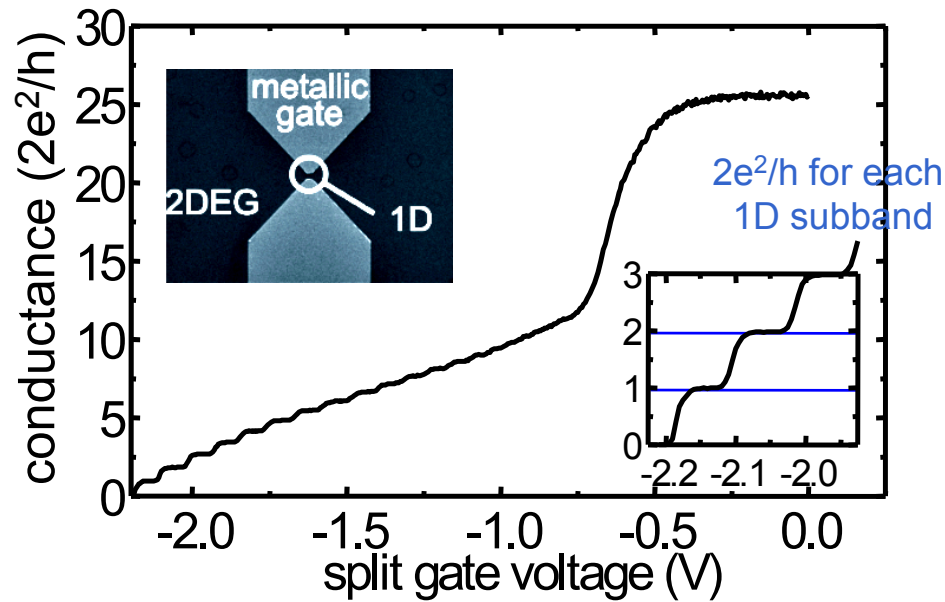
Cartoon

Sunday driving: lots of slow cars,
a few very fast ones (no crashes)



Equation

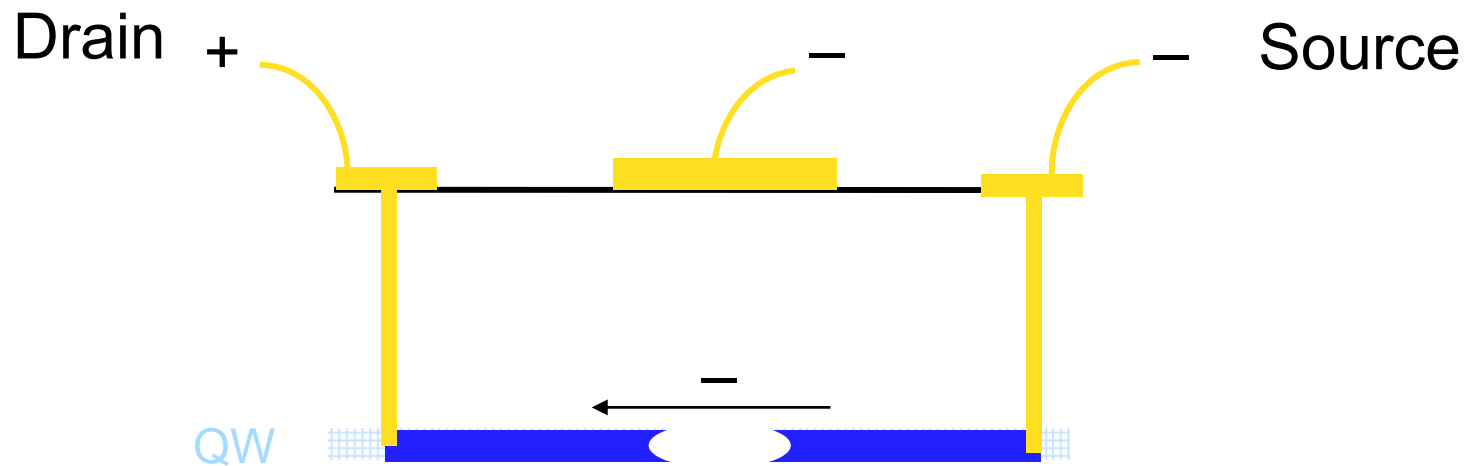
$$g \sim v_F N(E) \longrightarrow \text{independent of density}$$



conductance depends
on e , h only



Uses of Gated Electronic Structures

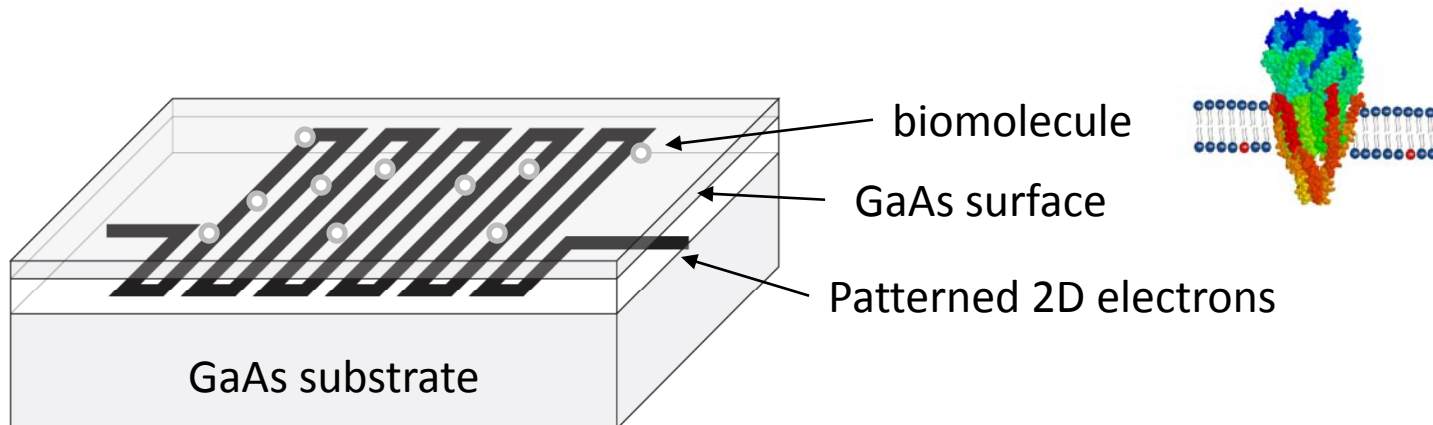


Charge on the Gate Affects Current Flow



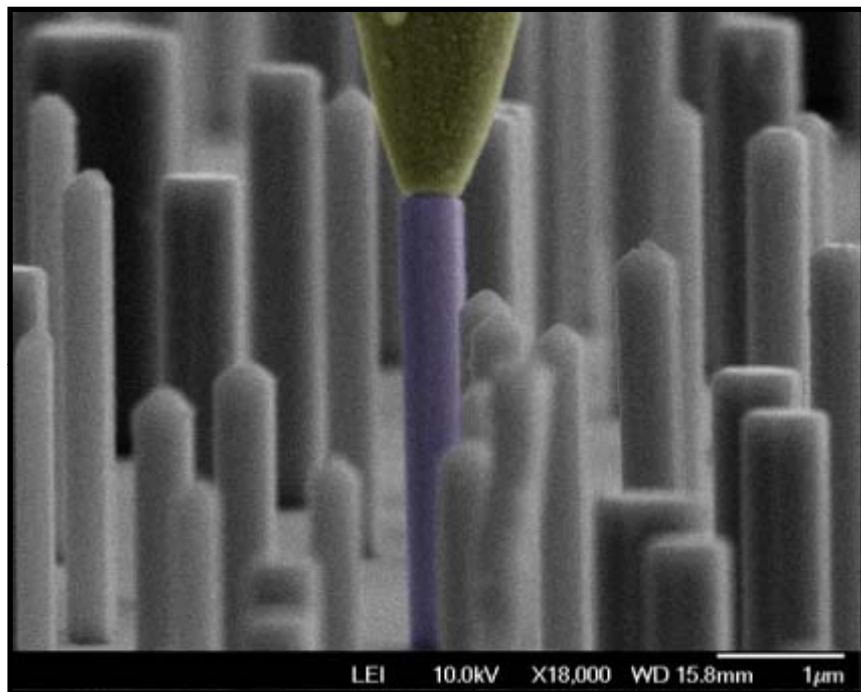
Semiconductor biosensor for charged proteins

- GaAs quantum wells create a two-dimensional electron gas below the surface of the semiconductor.
- The resistance of the 2D electrons will depend on the electric fields.
- Changes in the charge state of a biomolecule (e.g. membrane protein) on the surface will lead to changes in the local resistance.
- Initial device structure will be a meander line to maximize resistance changes
- Processed surface will be buried under 1 micron of GaAs to expose a uniform surface



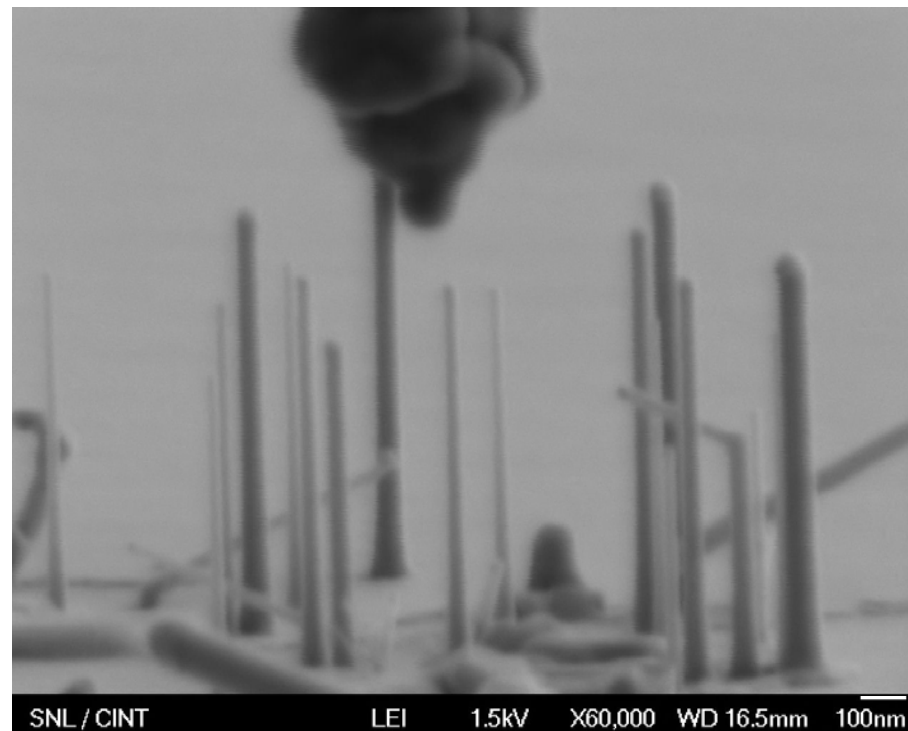


Nanowires



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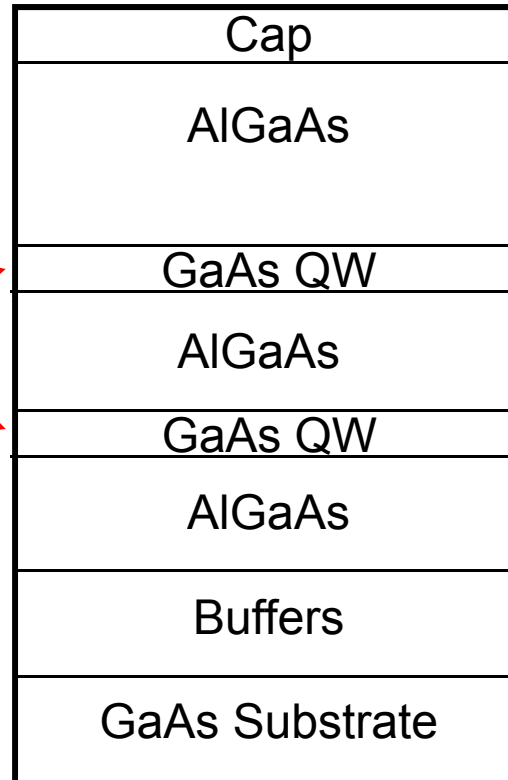
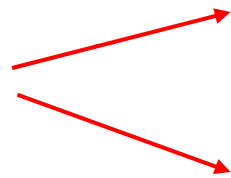
Ge nanowires $< 100\text{nm}$ diameter





Two Wire Structure

Electrons
confined

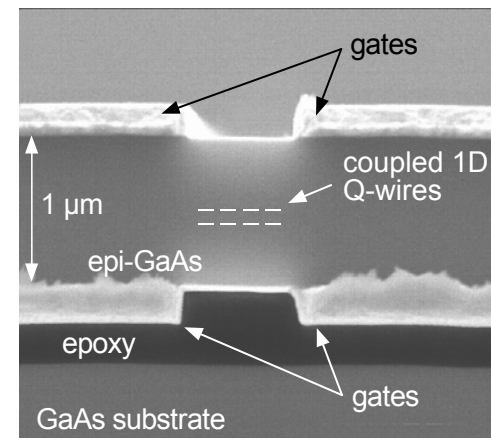
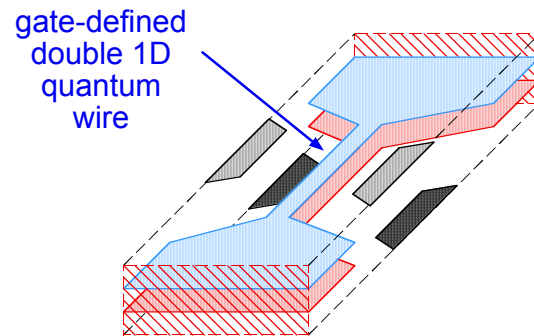
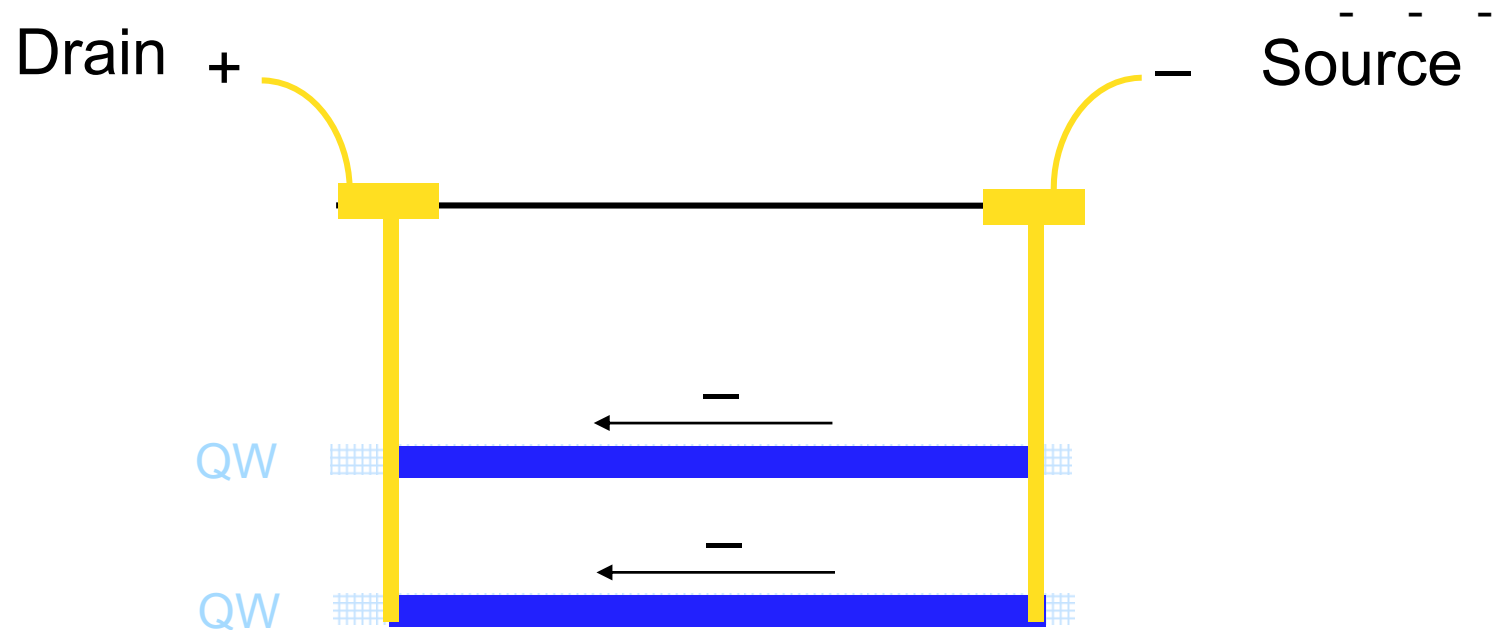


Thickness
Adjustable
(Interaction
Adjustable)



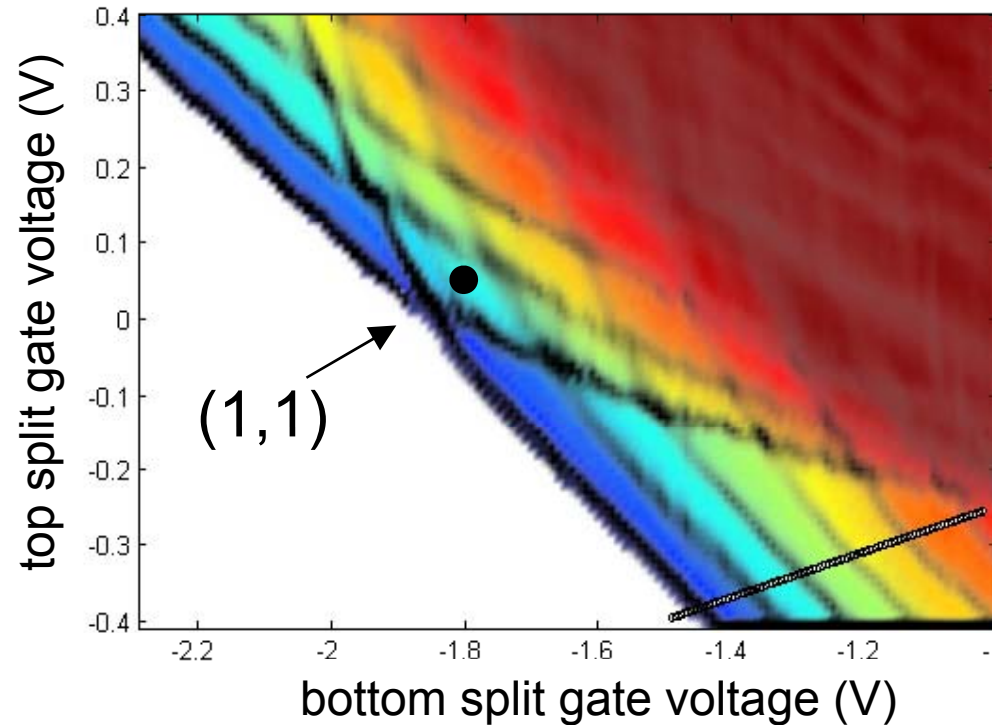


Double Quantum Wires





Precise Control of the 1D states w/ No Interaction



- The color scale corresponds to the conductance :

$$(2,0), (0,2), (1,1) \rightarrow 2G_0$$

$$(3,0), (0,3), (2,1) \rightarrow 3G_0$$

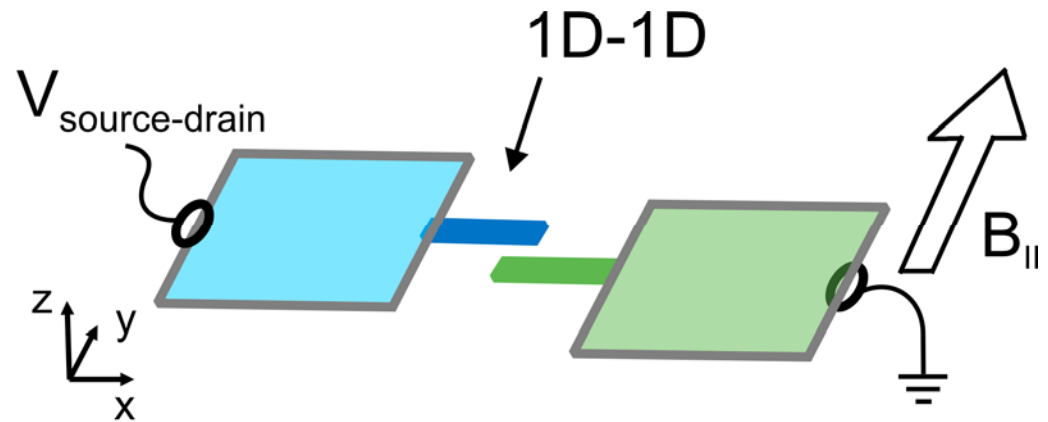
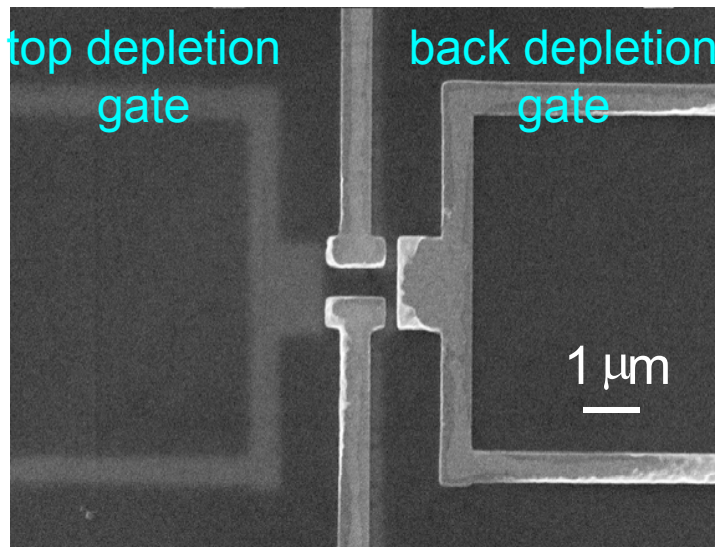
$$(6,0), (0,6), (3,3) \rightarrow 6G_0$$

where $G_0 = 2e^2/h$.



Vertically coupled double quantum wires

- Study nanoelectronic interactions
- Design systems for coherent transport studies

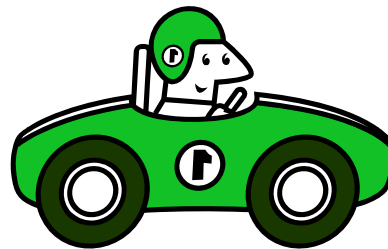




Interactions Can Lead to Tunneling (cartoon view)

- Tunneling must conserve energy and momentum
- Tunneling must be from an occupied state to an unoccupied state

wire 1



No tunneling
(no unoccupied state)

wire 2

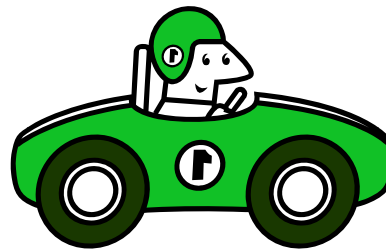




Interactions Can Lead to Tunneling (cartoon view)

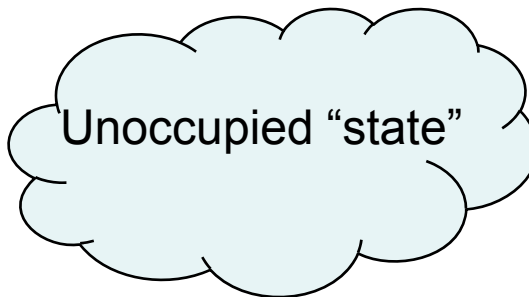
- Tunneling must conserve energy and momentum
- Tunneling must be from an occupied state to an unoccupied state

wire 1



No tunneling
(momentum not conserved)

wire 2





Interactions Can Lead to Tunneling (cartoon view)

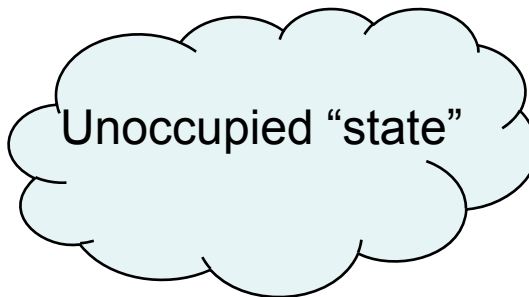
- Tunneling must conserve energy and momentum
- Tunneling must be from an occupied state to an unoccupied state

wire 1



Tunneling occurs!

wire 2

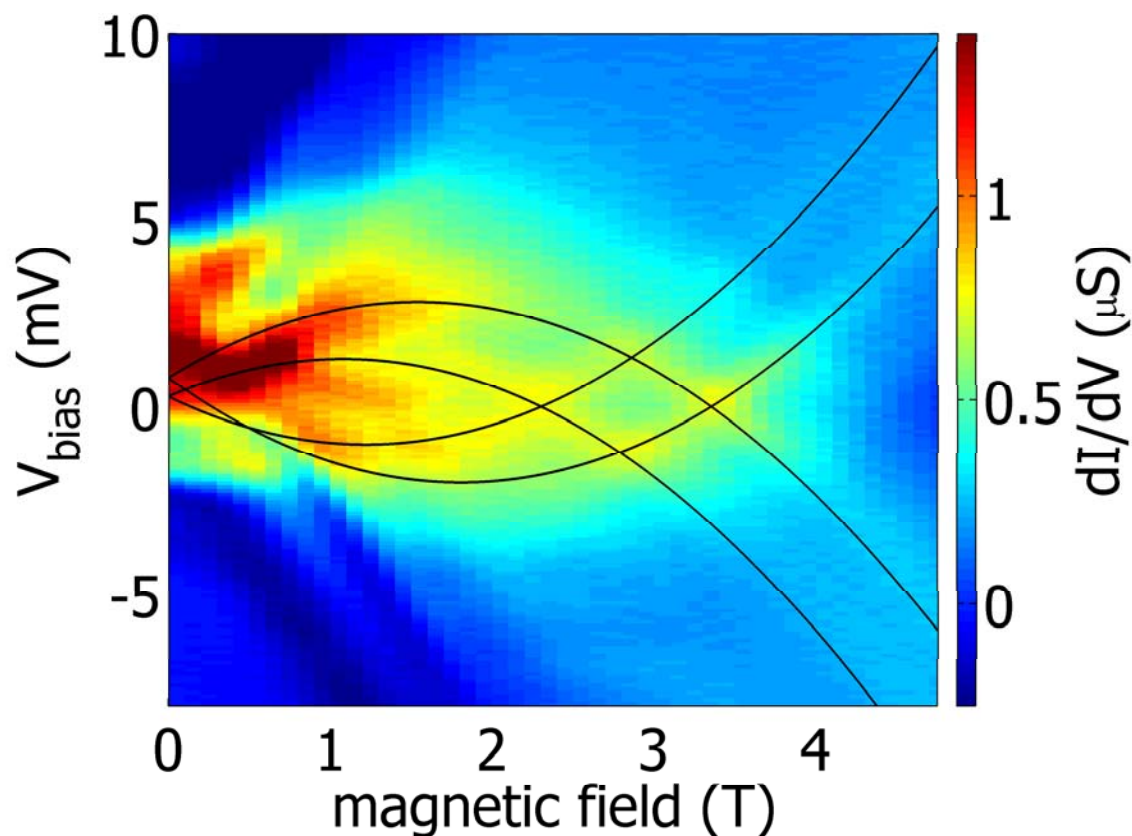
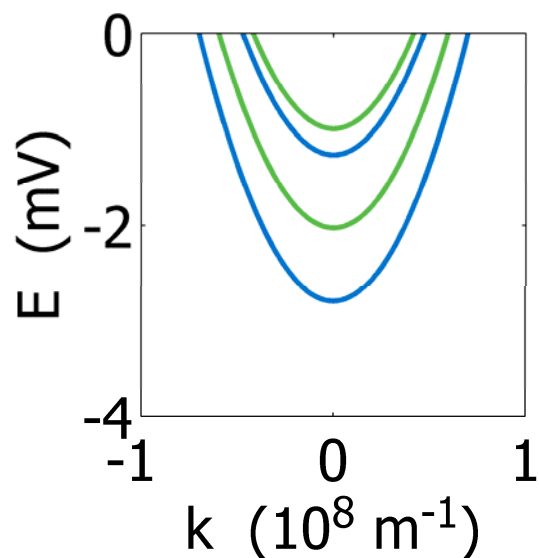




Spectroscopy at (2,2)

Notable features

- Crossing points at high field
- Complicated and broad structure at low field



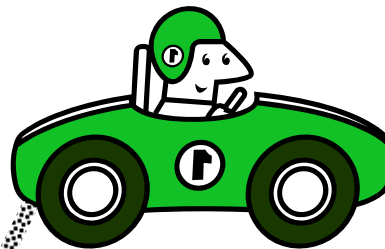
Non-interacting electron model (lines) provides a good starting point to understand results. Additional features may arise from interactions.



Interactions Can Lead to Coulomb Drag(cartoon view)

- No voltage on wire 2 so carriers (cars) not moving
- Moving carriers in wire 1 can drag those in 2 by Coulomb interactions

wire 1



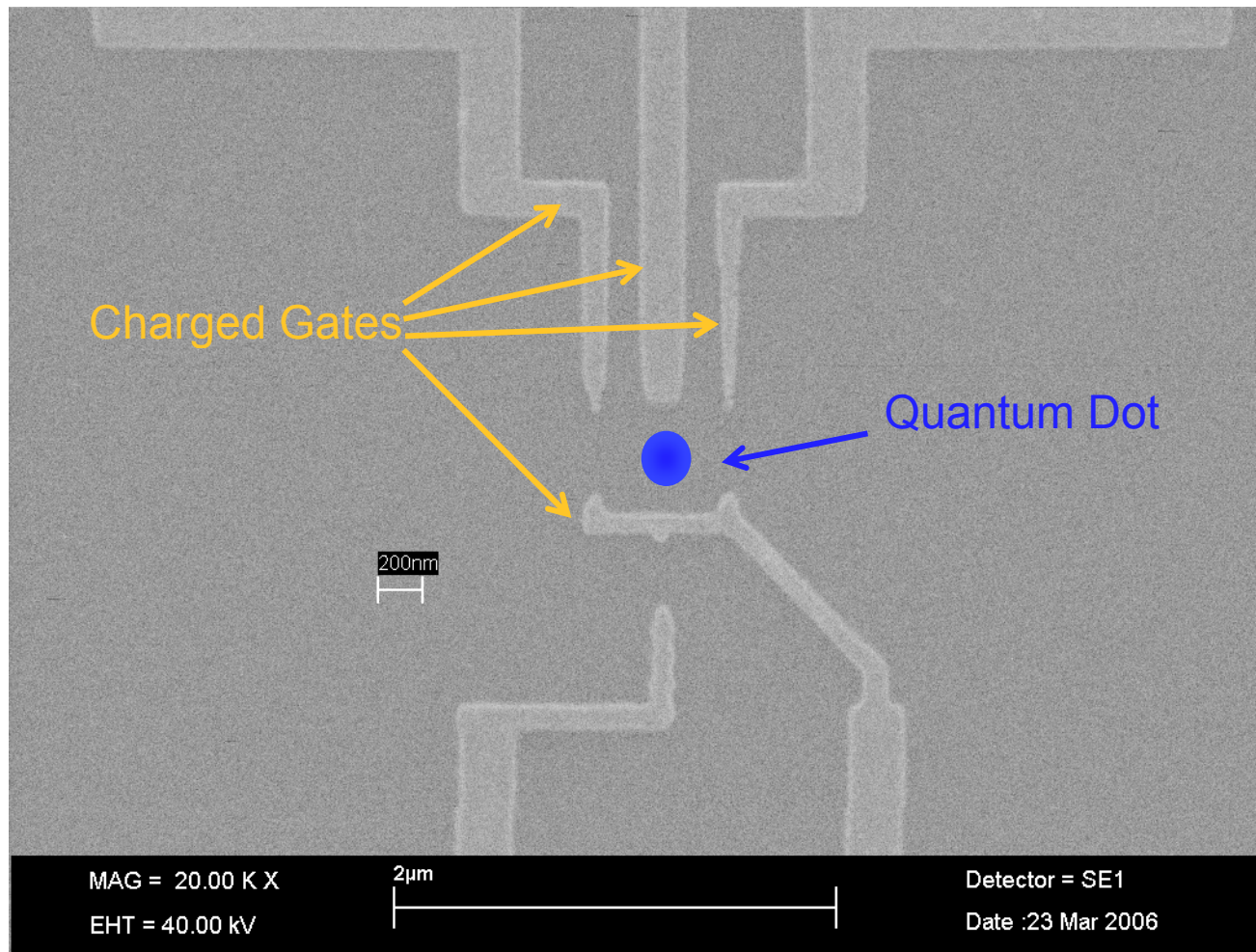
wire 2



Coulomb
Interaction



Quantum Dot w/ Charge Sensor





For the Chemists

- Standard Optical Techniques to Identify Chemical
 - Adsorption, Luminescence, Transmission,...
- Need Laser (gas lasers are not small)



Gas Laser



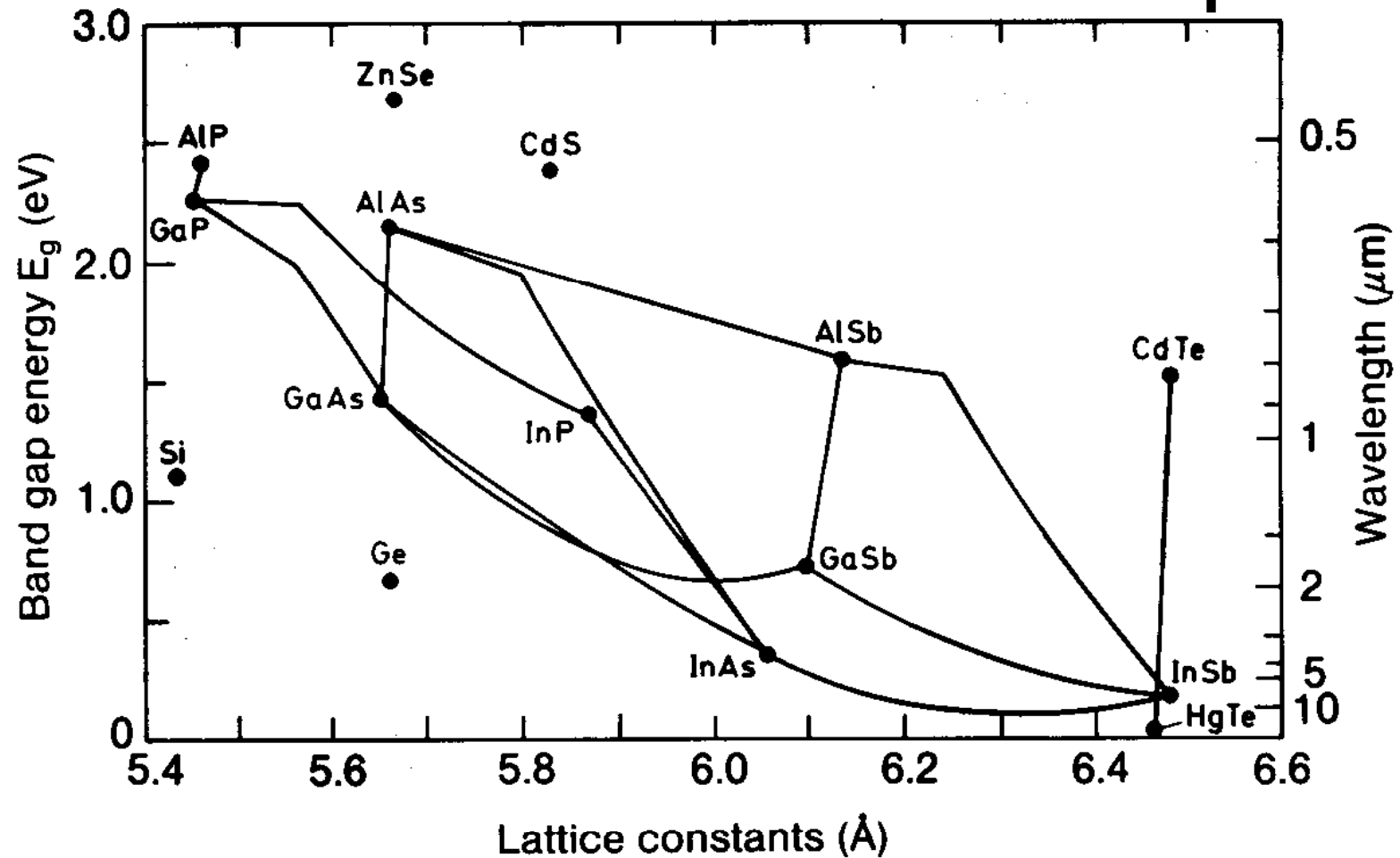


For the Chemists

- Standard Optical Techniques to Identify Chemical
 - Adsorption, Luminescence, Transmission,...
- Need Laser
 - (gas lasers are not small)
- Semiconductor lasers
 - (not new but are limited)



Semiconductor Roadmap





For the Chemists

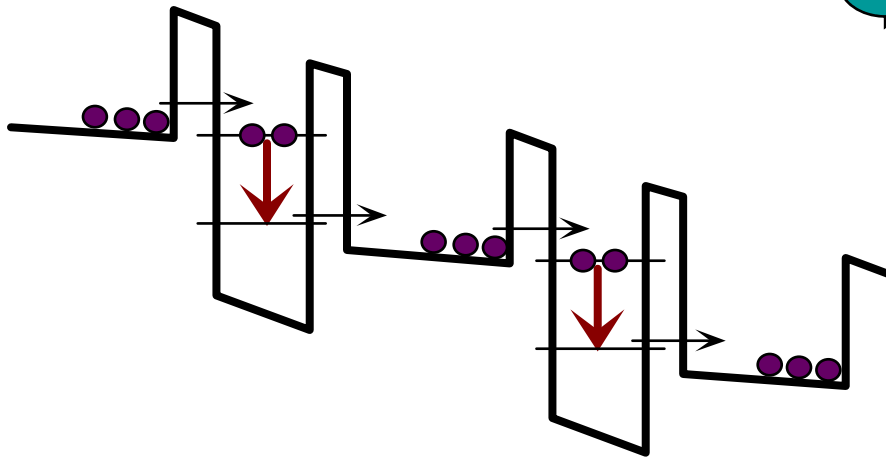
- Standard Optical Techniques to Identify Chemical
 - Adsorption, Luminescence, Transmission,...
- Need Laser
 - (gas lasers are not small)
- Semiconductor lasers
 - (new but are limited)
- **New Approach - Quantum Cascade Lasers**



What is a QCL

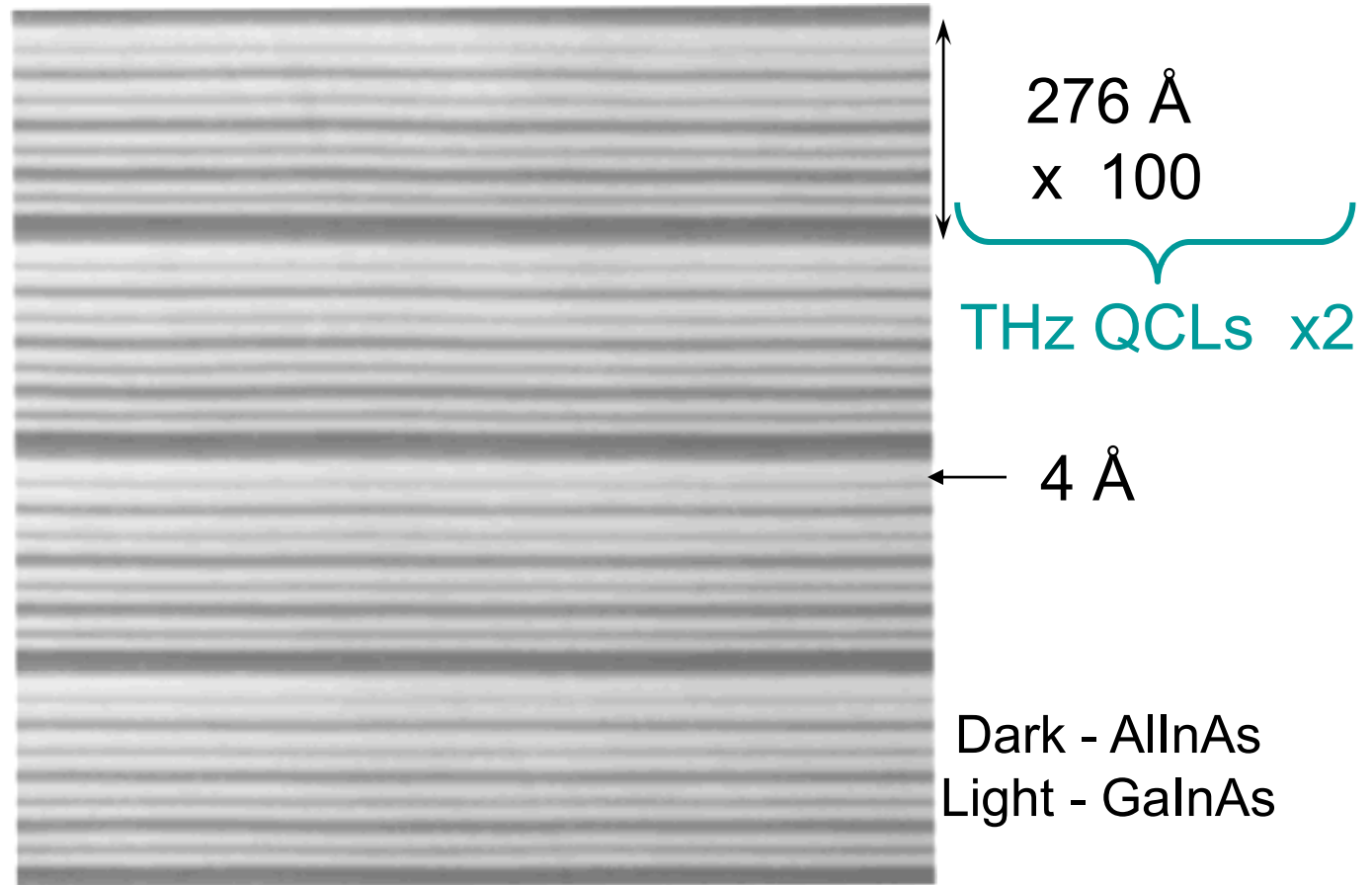
QCL - Quantum Cascade Laser

- ↳ Semiconductor laser (unipolar)
- ↳ Frequency defined by layer thickness
- ↳ Tens to thousands of MBE layers
- ↳ Watts of power
- ↳ Broad wavelength range
- ↳ 2.1 to 150 microns





Why You Need to be NICE to Your Grower



Courtesy of
Claire Gmachl et al

Lucent Technologies
Bell Labs Innovations





THz QCL Example Structure

Many
Layers

Repeat
163
times

Total Active
Thickness
~10 μm

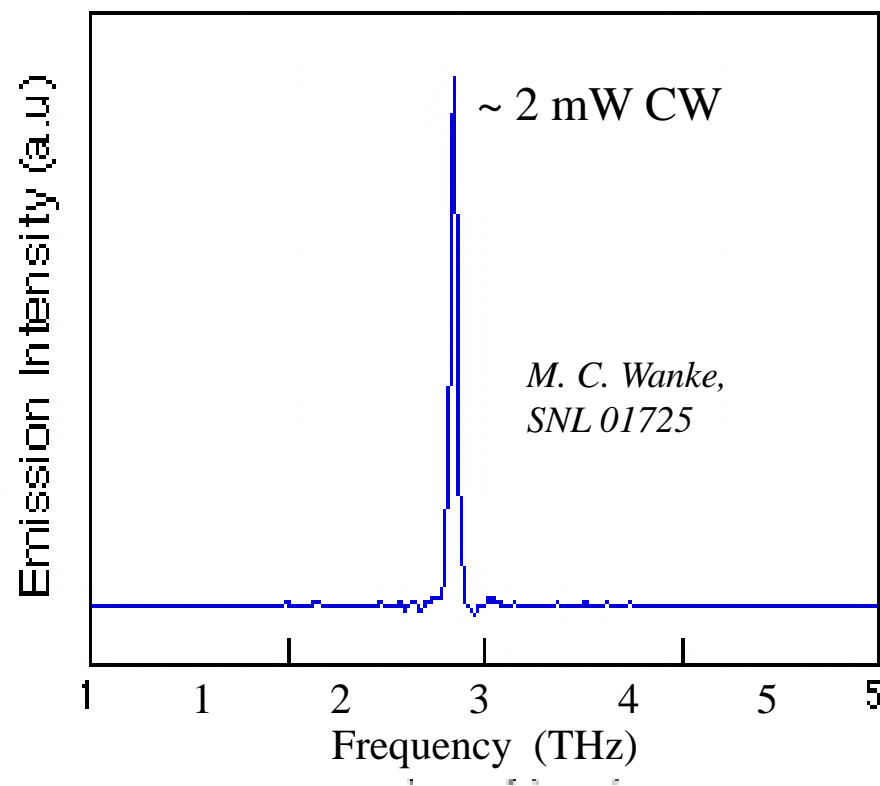
GaAs	LTG (250 C) cap layer	35 A
GaAs	$5 \times 10^{19} \text{ cm}^{-3}$	100 A
GaAs	$5 \times 10^{18} \text{ cm}^{-3}$	500 A
$\text{Al}_{0.15}\text{Ga}_{0.85}\text{As}$	undoped	33.9 A (12 ML)
GaAs	$1.9 \times 10^{16} \text{ cm}^{-3}$	161.0 A (57 ML)
$\text{Al}_{0.15}\text{Ga}_{0.85}\text{As}$	undoped	31.1 A (11 ML)
GaAs	undoped	96.1 A (34 ML)
$\text{Al}_{0.15}\text{Ga}_{0.85}\text{As}$	undoped	48.0 A (17 ML)
GaAs	undoped	53.7 A (19 ML)
$\text{Al}_{0.15}\text{Ga}_{0.85}\text{As}$	undoped	11.3 A (4 ML)
GaAs	undoped	53.7 A (19 ML)
$\text{Al}_{0.15}\text{Ga}_{0.85}\text{As}$	undoped	14.1 A (5 ML)
GaAs	undoped	45.2 A (16 ML)
$\text{Al}_{0.15}\text{Ga}_{0.85}\text{As}$	undoped	11.3 A (4 ML)
GaAs	undoped	48.0 A (17 ML)
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GaAs	undoped	96.1 A (34 ML)
$\text{Al}_{0.15}\text{Ga}_{0.85}\text{As}$	undoped	48.0 A (17 ML)
GaAs	$3 \times 10^{18} \text{ cm}^{-3}$	0.8 μm
$\text{Al}_{0.55}\text{Ga}_{0.45}\text{As}$	undoped	0.1 μm
S. I. GaAs substrate		

Thin
Accurate
Layers



QCL Output

2.8 THz QCL (EA1247)

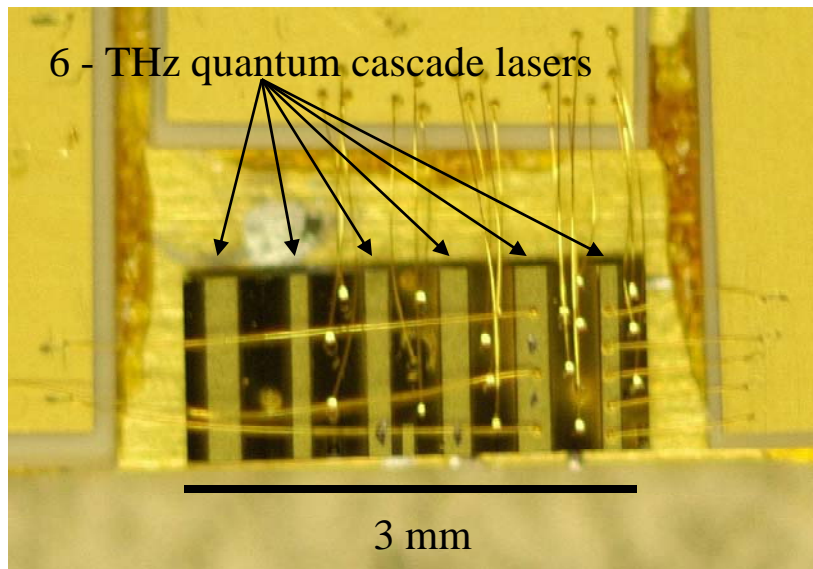




Which do want for a Satellite?



Coherent/DEOS molecular gas tube THz laser



Mounted chip with 6 THz lasers (1.5 x 3 mm)



Conclusion

MBE is a powerful technique with many applications in nanotechnology

